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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Group Art Unit: 2812
Examiner: Jennifer M. Kennedy

In Re PATENT APPLICATION of:

Applicant(s): Osamu KATO)

Serial No.: 10/689,032)

Filing Date: October 21, 2003)

For: METHOD FOR FABRICATING A GATE)
MASK OF A SEMICONDUCTOR)
DEVICE)

Docket No.: FUJI 138)

**PETITION FOR
THREE-MONTH
EXTENSION OF TIME**

September 22, 2005

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

It is respectfully requested that the period for replying to the Examiner's Action mailed on March 25, 2005, be extended for three months under the provisions of 37 C.F.R. 1.136(a).

The applicable extension fee of \$1,020.00 pursuant to 37 C.F.R. 1.17(a) (3) is submitted herewith.

Should the remittance be accidentally missing or insufficient, the Commissioner is hereby authorized to charge the fee to our Deposit Account No. 18-0002, and advise us accordingly.

Respectfully submitted,

September 22, 2005

Date

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